L Number	Hits	Search Text	DB	Time stamp
-	441	(349/188-192).CCLS.	USPAT; US-PGPUB;	2004/03/11 14:45
-	0	(("349/188-192").CCLS.) and "in line system"	JPO USPAT; US-PGPUB; JPO	2001/11/29 14:28
_	0	(("349/188-192").CCLS.) and "in-line system"	USPAT;	2001/11/29 14:28
-	8	(("349/188-192").CCLS.) and "production line"	JPO * * * USPAT; US-PGPUB; JPO	2001/11/29 14:30
_	2	(("349/188-192").CCLS.) and "assembly line"	USPAT; US-PGPUB; JPO	2001/11/29 14:31
-	5	(("349/188-192").CCLS.) and ("manufacturing line" "line of manufacture")	USPAT; US-PGPUB; JPO	2001/11/29 14:32
-	14	((("349/188-192").CCLS.) and "production line") ((("349/188-192").CCLS.) and "assembly line") ((("349/188-192").CCLS.) and ("manufacturing line" "line of	USPAT; US-PGPUB; JPO	2001/11/29 14:32
_	0	manufacture")) (((("349/188-192").CCLS.) and "production line") ((("349/188-192").CCLS.) and "assembly line") ((("349/188-192").CCLS.) and ("manufacturing line" "line of	USPAT; US-PGPUB; JPO	2001/11/29 14:33
-	10	manufacture"))) and ("spacer dispensing" "spacer dispersing") (((("349/188-192").CCLS.) and "production line") ((("349/188-192").CCLS.) and "assembly line") ((("349/188-192").CCLS.) and ("manufacturing line" "line of manufacture"))) and (machine apparatus	USPAT; US-PGPUB; JPO	2001/11/29 14:34
	478	station) (349/188-192).CCLS.	USPAT; US-PGPUB; JPO	2002/07/15 08:48
-	0	((349/188-192).CCLS.) and phillipsas.	USPAT; US-PGPUB; EPO; JPO	2002/07/15 08:49
_	. 0	((349/188-192).CCLS.) and phillips.as.	USPAT; US-PGPUB; EPO; JPO	2002/07/15 08:49
-	0	((349/188-192).CCLS.) and phillips.astx.	USPAT; US-PGPUB; EPO; JPO	2002/07/15 08:51
-	3	((349/188-192).CCLS.) and "deposit liquid crystal"	USPAT; US-PGPUB; EPO; JPO	2002/07/15 09:47
-	1	("6414733").PN.	USPAT; US-PGPUB; EPO; JPO	2002/07/15 09:47
-	4	(((349/188-192).CCLS.) and "deposit liquid crystal") (("6414733").PN.)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 08:40
-	1084	(349/153).CCLS.	USPAT; US-PGPUB; EPO; JPO	2002/07/15 09:51
-	0	((349/153).CCLS.) and "first hardening"	USPAT; US-PGPUB; EPO; JPO	2002/07/15 09:53
_	0	((349/153).CCLS.) and "reaction prevention"	USPAT; US-PGPUB; EPO; JPO	2002/07/15 09:53
-	0	((349/153).CCLS.) and "pre polymerize"	USPAT; US-PGPUB; EPO; JPO	2002/07/15 09:54

-	0	((349/153).CCLS.) and "pre-polymerize"	USPAT; US-PGPUB;	2002/07/15 09:54
_	52	((349/153).CCLS.) and contamination	EPO; JPO USPAT; US-PGPUB;	2002/07/15 09:54
-	27854	349\$.ccls.	EPO; JPO USPAT; US-PGPUB;	2002/07/16 07:19
-	358	349\$.ccls. and (rotat\$5 near3 substrate)	EPO; JPO USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:20
-	574	349\$.ccls. and (spin\$3 near3 substrate)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:21
-	260	(349\$.ccls. and (rotat\$5 near3 substrate) and (rotat\$5 near2 substrate)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:22
-	422	(349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:21
_	231	((349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)) and (spin\$3 near substrate)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:22
_	151	((349\$.ccls. and (rotat\$5 near3 substrate)) and (rotat\$5 near2 substrate)) and (rotat\$5 near substrate)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:22
-	106		USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:23
_	103	and ("liquid crystal" same rotat\$5) (((349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)) and (spin\$3 near substrate)) and ("liquid	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:24
	204	crystal" same spin\$3) ((((349\$.ccls. and (rotat\$5 near3 substrate)) and (rotat\$5 near2 substrate)) and (rotat\$5 near substrate)) and ("liquid crystal" same rotat\$5)) ((((349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)) and (spin\$3 near substrate)) and ("liquid	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:24
-	174	crystal" same spin\$3)) (((((349\$.ccls. and (rotat\$5 near3 substrate)) and (rotat\$5 near2 substrate)) and (rotat\$5 near substrate)) and ("liquid crystal" same rotat\$5)) ((((349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)) and (spin\$3 near substrate)) and ("liquid	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:29
-	147	crystal" same spin\$3))) and @ad<20000419 ((((((349\$.ccls. and (rotat\$5 near3 substrate)) and (rotat\$5 near2 substrate)) and (rotat\$5 near substrate)) and ("liquid crystal" same rotat\$5)) ((((349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)) and (spin\$3 near2 substrate)) and (rotat\$5)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:30
_	147	<pre>((((((((349\$.ccls. and (rotat\$5 near3 substrate)) and (rotat\$5 near2 substrate)) and (rotat\$5 near substrate)) and ("liquid crystal" same rotat\$5)) ((((349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)) and (spin\$3 near substrate)) and ("liquid crystal" same spin\$3)) and @ad<20000419) not (resist same spin\$3)) not (resist same rotat\$5)</pre>	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:31

				1 0 0 0 0 /0 0 /0 0
-	146	((((((((349\$.ccls. and (rotat\$5 near3	USPAT;	2002/07/16
		substrate)) and (rotat\$5 near2	US-PGPUB; EPO; JPO	07:32
		substrate)) and (rotat\$5 near substrate)) and ("liquid crystal" same rotat\$5))	EPO; JPO	
	ļ	((((349\$.ccls. and (spin\$3 near3		İ
	İ	substrate)) and (spin\$3 near2 substrate))		
	ł	and (spin\$3 near substrate)) and ("liquid		
		crystal" same spin\$3))) and @ad<20000419)		
		not (resist same spin\$3)) not (resist	İ	
		same rotat\$5)) not (photo same rotat\$5)		
_	123	(((((((((349\$.ccls. and (rotat\$5 near3	USPAT;	2002/07/16
		substrate)) and (rotat\$5 near2	US-PGPUB;	07:32
		substrate)) and (rotat\$5 near substrate))	EPO; JPO	
		and ("liquid crystal" same rotat\$5))		
		((((349\$.ccls. and (spin\$3 near3		
		substrate)) and (spin\$3 near2 substrate))		
		and (spin\$3 near substrate)) and ("liquid		
		crystal" same spin\$3))) and @ad<20000419)		
		not (resist same spin\$3)) not (resist		
		same rotat\$5)) not (photo same rotat\$5))		
-	110	not (polymer same rotat\$5)	HCDAM:	2002/07/16
-	119	((((((((((((((((((((((((((((((((((((((USPAT;	2002/07/16
		substrate)) and (rotat\$5 near2	US-PGPUB;	07:33
		substrate)) and (rotat\$5 near substrate)) and ("liquid crystal" same rotat\$5))	EPO; JPO	
		((((349\$.ccls. and (spin\$3 near3		<u>.</u>
		substrate)) and (spin\$3 near2 substrate))		
	1	and (spin\$3 near substrate)) and ("liquid		
		crystal" same spin\$3))) and @ad<20000419)		
		not (resist same spin\$3)) not (resist		
		same rotat\$5)) not (photo same rotat\$5))		
		not (polymer same rotat\$5)) not (photo		
		same spin\$3)		
-	97		USPAT;	2002/07/16
1	1	substrate)) and (rotat\$5 near2	US-PGPUB;	07:34
1		<pre>substrate)) and (rotat\$5 near substrate))</pre>	EPO; JPO	
1	1	and ("liquid crystal" same rotat\$5))		
		((((349\$.ccls. and (spin\$3 near3		
1		substrate)) and (spin\$3 near2 substrate))		
1		and (spin\$3 near substrate)) and ("liquid		
		crystal" same spin\$3))) and @ad<20000419)		
1		not (resist same spin\$3)) not (resist		
		same rotat\$5)) not (photo same rotat\$5))	1	·
i		not (polymer same rotat\$5)) not (photo		
l _	1	<pre>same spin\$3)) not (polymer same spin\$3) ((((((((((((349\$.ccls. and (rotat\$5 near3))))))))))))))))))))))))))))))))))))</pre>	USPAT;	2002/07/16
-	1	substrate)) and (rotat\$5 near2	USPAT; US-PGPUB;	07:36
ĺ		substrate)) and (rotats nearz substrate))	EPO; JPO	07.30
		and ("liquid crystal" same rotat\$5))	110, 010	
]	((((349\$.ccls. and (spin\$3 near3		
		substrate)) and (spin\$3 near2 substrate))		
]	and (spin\$3 near substrate)) and ("liquid		
	l l	crystal" same spin\$3))) and @ad<20000419)		
		not (resist same spin\$3)) not (resist		
		same rotat\$5)) not (photo same rotat\$5))		
		not (polymer same rotat\$5)) not (photo		
		<pre>same spin\$3)) not (polymer same spin\$3))</pre>		
!		and (fill same (rotat\$5 spin\$3))		
-	137	(349/189).CCLS.	USPAT;	2002/07/16
			US-PGPUB;	07:36
			EPO; JPO	
-	1	((349/189).CCLS.) and (fill same (rotat\$5	USPAT;	2002/07/16
		spin\$3))	US-PGPUB;	07:37
		(4240/400)	EPO; JPO	0000/05/55
_	43	((349/189).CCLS.) and (rotat\$5 spin\$3)	USPAT;	2002/07/16
			US-PGPUB;	07:38
_	30	///2/0/100\ CCIC \ and /matatic animica\\	EPO; JPO	2002/07/16
-	32	(((349/189).CCLS.) and (rotat\$5 spin\$3)) and ((rotat\$5 spin\$3) same liquid)	USPAT;	2002/07/16 07:39
		and ((rotates spines) same riquid)	US-PGPUB; EPO; JPO	01:33
L			חבט, טבט	

_	2	("5461502").PN.	USPAT;	2002/07/16
		,	US-PGPUB;	08:40
			EPO; JPO	
-	1	"09/838,385"	USPAT;	2002/11/25
			US-PGPUB;	10:45
			EPO; JPO	
-	499	(349/188-192).CCLS.	USPAT;	2002/11/25
			US-PGPUB;	13:16
İ			JPO	
-	531	(349/188-192).CCLS.	USPAT;	2003/07/10
			US-PGPUB;	11:20
			JPO	
-	34	((349/188-192).CCLS.) not @pd<20021101	USPAT;	2003/07/10
			US-PGPUB;	11:20
			EPO; JPO	
-	2	"09/838385"	USPAT;	2004/03/11
			US-PGPUB;	14:46
			EPO; JPO	